Practitioner's Docket No.: 782_206

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

Tomohiko SHIBATA, Keiichiro ASAI, Yukinori

NAKAMURA and Mitsuhiro TANAKA

RECEIVED CENTRAL FAX CENTER

Ser. No.: 10/017,325

Group Art Unit: 2811

DEC 0 9 2004

Filed: December 14, 2001

Examiner: Junghwa M. Im

Confirmation No.: 8198

For:

SEMICONDUCTOR ELEMENT

Mail Stop AF

Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that this paper is being facsimile transmitted to 703-872-9306 in the Patent and Tradefliark Office on December 9, 2004.

REQUEST FOR RECONSIDERATION AFTER FINAL REJECTION

Sir:

The following remarks are in response to the Office Action mailed September 9, 2004.

Claims 1-6, 8 and 10-15 are pending herein. Claims 1-6, 8 and 10-15 were ı. rejected under §103(a) over Ohba in view of Ogawa. This rejection is respectfully traversed.

As discussed in the June 16, 2004 Amendment, the entirety of which is incorporated herein by reference, pending independent claim 1 recites, among other things, a semiconductor element having an Al-including underlayer on a substrate, a buffer layer on the underlayer and a Ga-including semiconductor layer group on the buffer layer. As will be shown below, even if Ohba and Ogawa were combined as asserted in the Office Action, there would still be no disclosure or suggestion that the resultant structure would include an Alincluding underlayer on a substrate, a buffer layer on the underlayer and a Ga-including semiconductor layer group on the buffer layer, as claimed.